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(12) **United States Design Patent**  
**De Polo et al.**

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(54) **INDUSTRIAL MODEL OF A MOLD FOR FINGERNAILS**

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(\* ) Notice: This patent is subject to a terminal disclaimer.

(\*\* ) Term: **14 Years**

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(30) **Foreign Application Priority Data**

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(51) **LOC (7) Cl. .... 28-03**

(52) **U.S. Cl. .... D28/56**

(58) **Field of Search ..... D28/56; 132/73, 132/285, 319, 320; 2/21**

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*Primary Examiner*—Paula A. Mortimer

(57) **CLAIM**

The ornamental design for an industrial model of a mold for fingernails, as shown and described.

**DESCRIPTION**

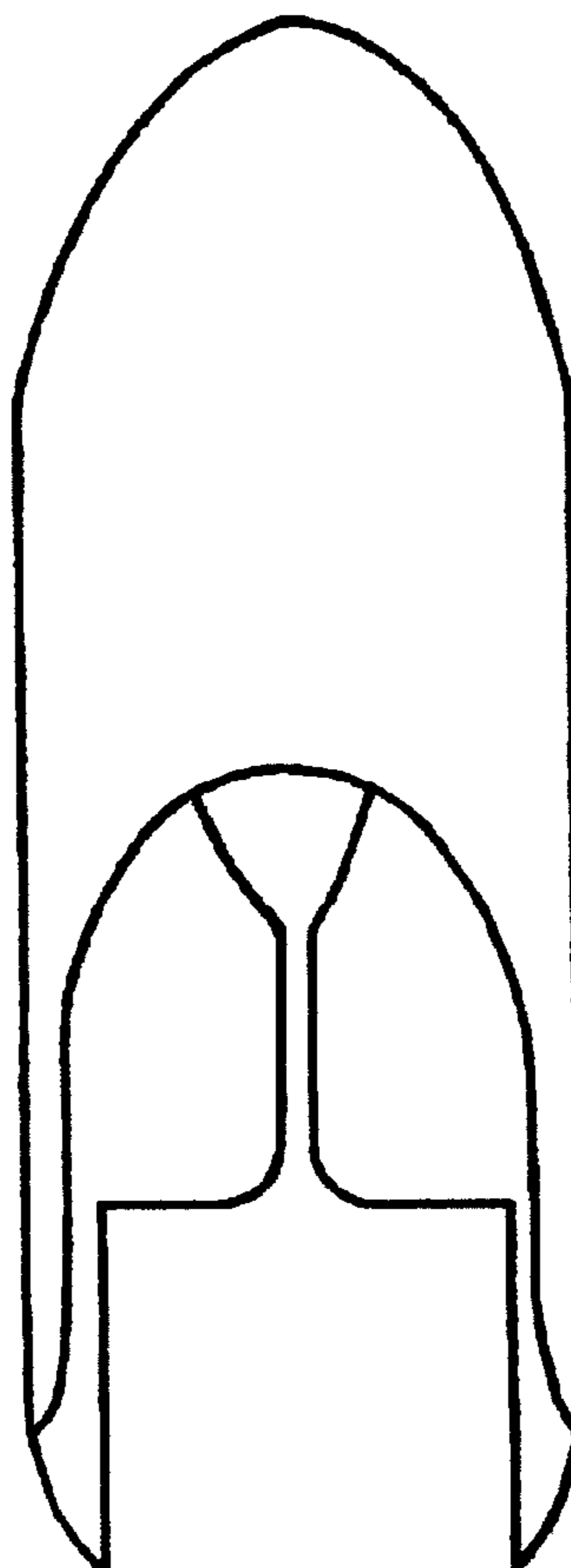
FIG. 1 is a front elevational view of an industrial model of a mold for fingernails showing my new design in an open position;

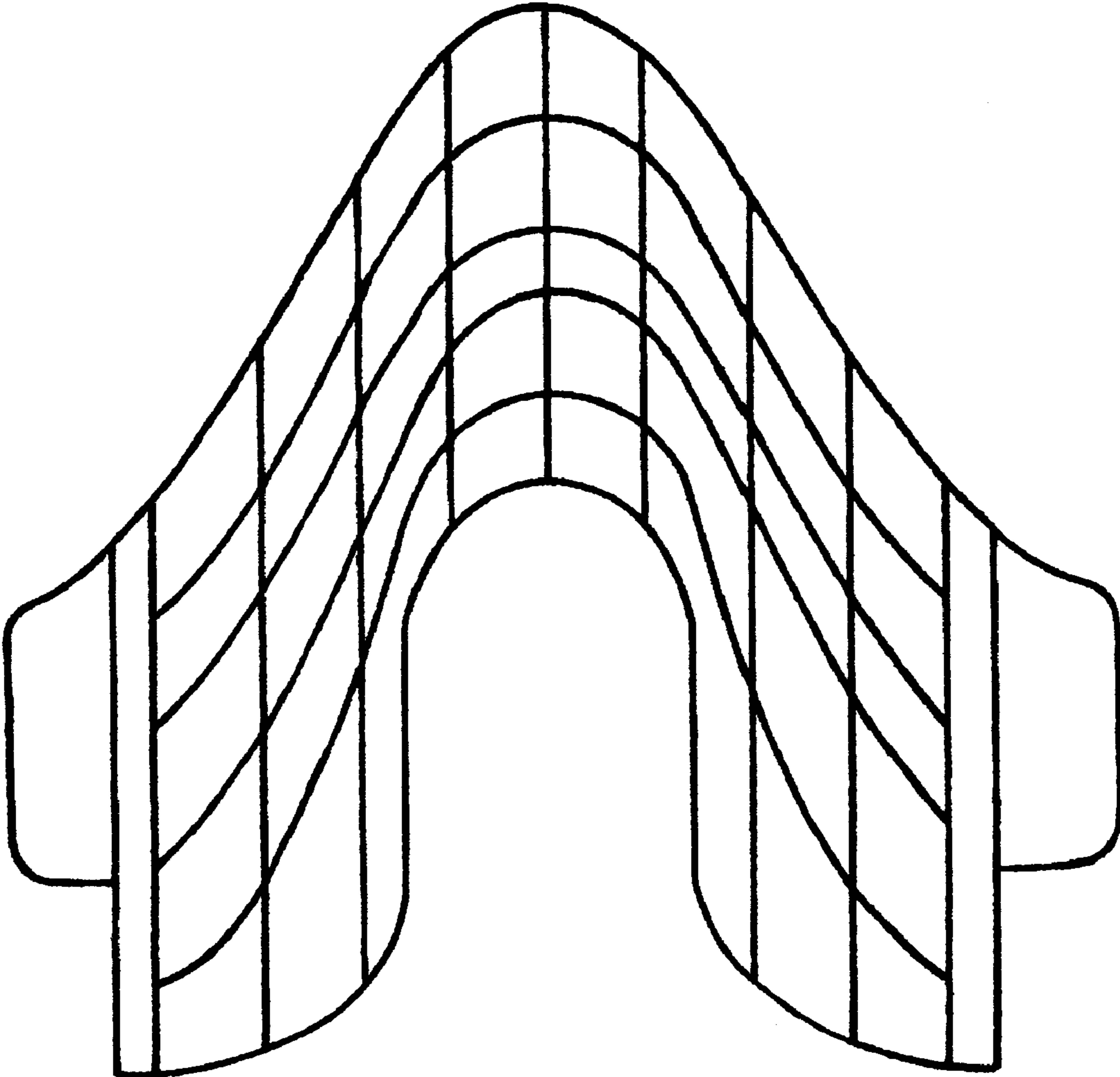
FIG. 2 is a front elevational view thereof in a closed position;

FIG. 3 is a rear elevational view thereof; and,

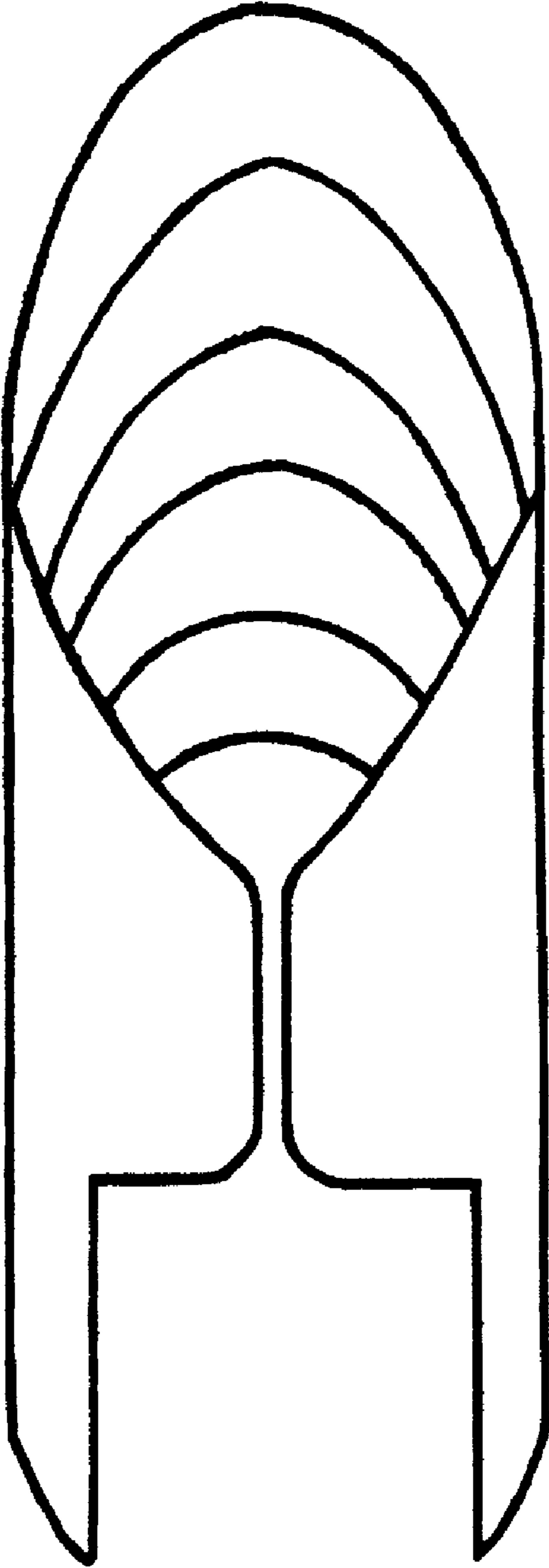
FIG. 4 is a side elevational view thereof, the opposite side is a mirror image.

**1 Claim, 4 Drawing Sheets**

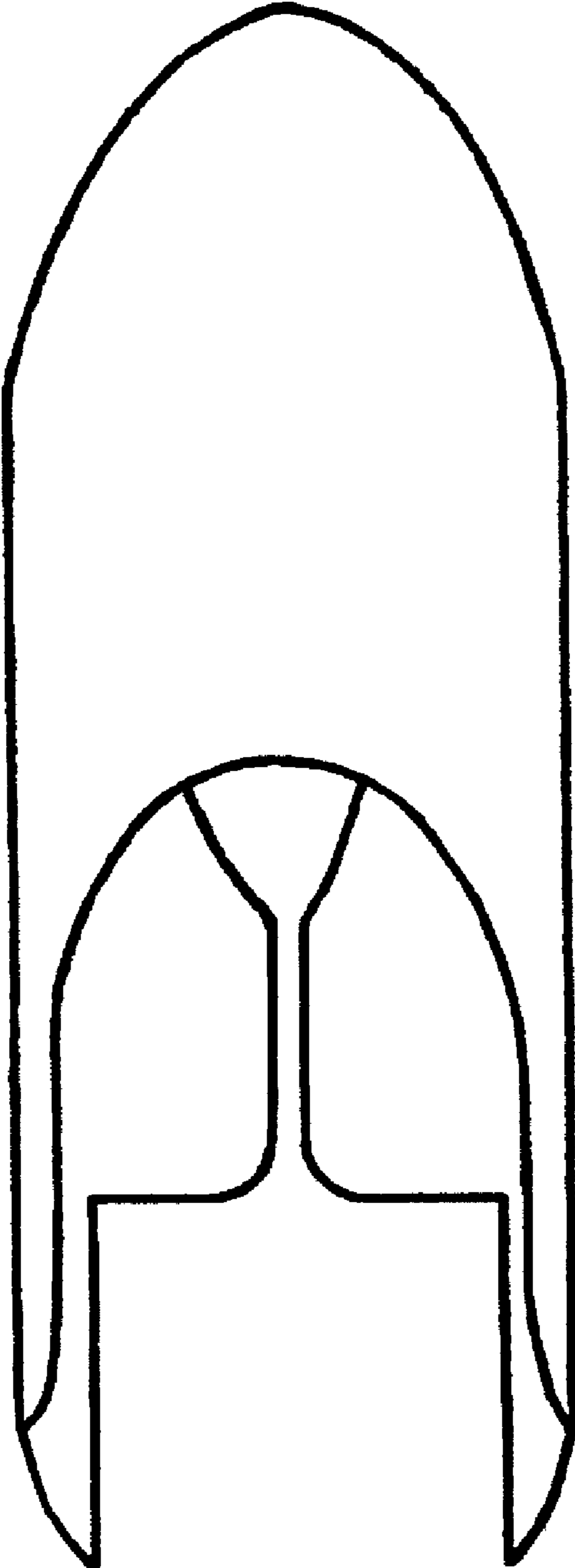




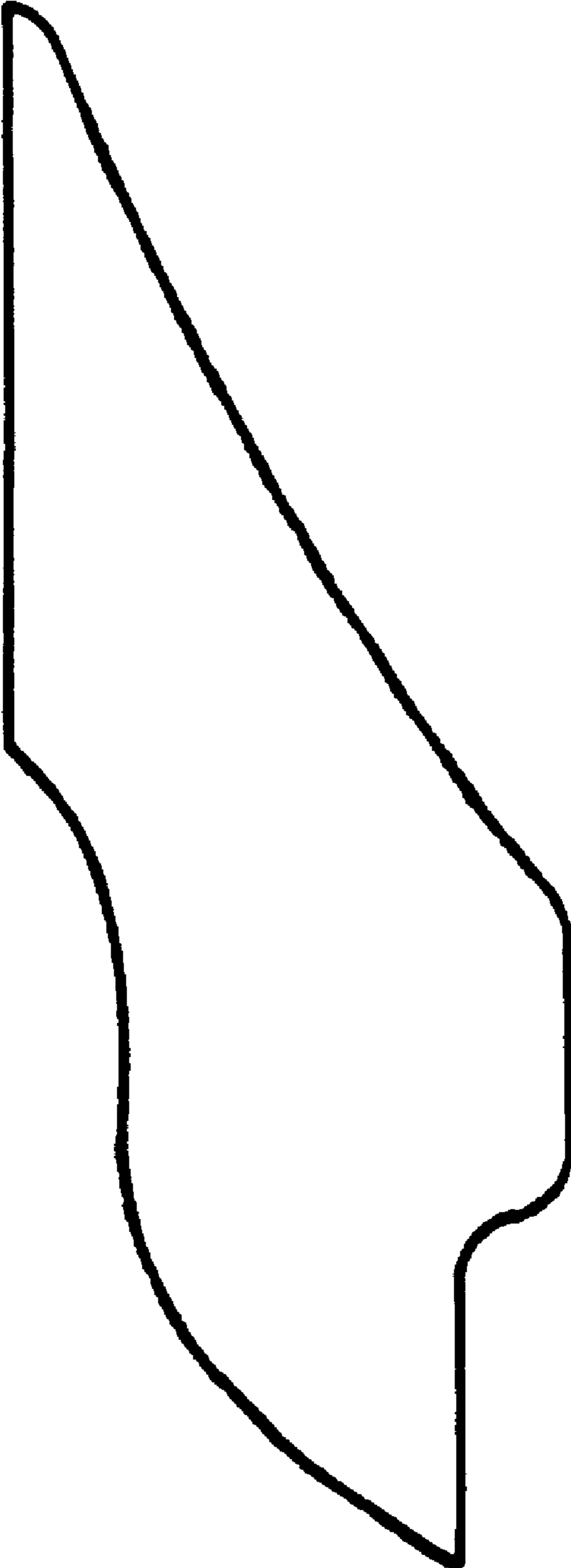
**FIG. 1**



**FIG. 2**



**FIG. 3**



**FIG. 4**